

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Y. Granik et al.

Attorney Docket No.: MEGC11733

Application No.: 09/898,431

Group Art Unit: 2123

Filed:

July 2, 2001

Title:

METHOD OF COMPENSATING FOR ETCH EFFECTS IN

PHOTOLITHOGRAPHIC PROCESSING

INFORMATION DISCLOSURE STATEMENT RECEIV

Seattle, Washington 981 JUL 1 9 2002

July 11, 2002

Technology Center 2100

TO THE COMMISSIONER FOR PATENTS:

Applicants are aware of the information listed in the attached form that may be material to the prosecution of the above-identified patent application.

- 1. X Copies of the listed patents, publications, and other information are enclosed for the Examiner's use.
- 2. X Pursuant to 37 C.F.R. § 1.97(b), this Information Disclosure Statement is being filed within three months of the filing date of the national application (other than a CPA), within three months of the date of entry of the national stage as set forth in 37 C.F.R. § 1.491 in an international application, before the mailing date of a first Office Action after the filing of an RCE.
- 3. X Pursuant to 37 C.F.R. § 1.704(d), this Information Disclosure Statement is accompanied by a statement that each item of information contained in this Information Disclosure statement was cited in a communication from a foreign patent office in a counterpart application. Such communication was received by an individual designated in 37 C.F.R. § 1.56(c) on June 17, 2002, which is not more than thirty days prior to the filing of this Information Disclosure Statement.
- 4. X The Commissioner is hereby authorized to charge any fees under 37 C.F.R. §§ 1.16, 1.17 and 1.18 which may be required during the entire pendency of the application, or credit any overpayment, to Deposit Account No. 03-1740. This

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authorization also hereby includes a request for any extensions of time of the appropriate length required upon the filing of any reply during the entire prosecution of this application.

Respectfully submitted,

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I hereby certify that this correspondence is being deposited with the U.S. Postal Service in a sealed envelope as first class mail with postage thereon fully prepaid and addressed to the Commissioner for Patents, U.S. Patent and Trademark Office, P.O. Box 2327, Arlington, VA 22202, on the below date.

Date:

RCT:yc



NFORMATION CITED BY APPLICANTS THAT MAY BE MATERIAL TO THE

PROSECUTION OF THE SUBJECT APPLICATION

icant:

Y. Granik et al.

Attorney Docket No. MEGC117332

Application No.: 09/898,431

Group Art Unit: 2123

Filed:

July 2, 2001

Title:

METHOD OF COMPENSATING FOR ETCH EFFECTS IN RECEIVED PHOTOLITHOGRAPHIC PROCESSING

U.S. PATENT DOCUMENTS

*Examiner Cite			Kind Date		Technoises	
Initials	No.	Document No.	Code	(mm/dd/yyyy)	Name	
	_ U1	5,682,323		10/28/1997	Pasch et al.	•
	U2	5,801,954		09/01/1998	Le et al.	

FOREIGN PATENT DOCUMENTS

None

OTHER INFORMATION

None

Examiner

Date Considered

*Examiner: Initial if reference considered, whether or not citation is in conformance with M.P.E.P. § 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.RCT:yc